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Herein, we have explored the use of a microfluidics platform for the exfoliation and oxidation of liquid gallium into ultrathin sheets of gallium oxide under continuous flow condition. The novel method developed here takes advantage of the high mass transfer in liquids and has the potential for creating high yielding thin sheets of oxidised gallium with insulating properties as well as acts as an active catalyst in hydrogen evolution reactions. This highlights the potential utility of the sheets as an alternative to the expensive and scarce noble metal based electrocatalysts

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High shear *in situ* exfoliation of 2D gallium oxide sheets from centrifugally derived thin films of liquid gallium

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The potential of two dimensional (2D)-nanomaterials for tackling some of the fundamental issues facing humanity have emerged from the discovery of graphene. There is now a diversity of such materials with recent attention turning to 2D materials of the post-transition metal elements [1-3], in particular material derived from liquid metals and eutectic melts below 330 °C where processing is more flexible and in the temperature regime suitable for industry. These 2D materials can have useful properties, along with their corresponding oxidised material, which can be accessed directly from liquid metals. Centrifugal thinning of liquid metals with solvents under shear stress has potential in both facilitating exfoliation and oxidation of 2D materials, as well as controlling the formation of nanomaterials in general, with control over their morphology, phase and dimensions. This has been explored for liquid gallium using an angled vortex fluidic device (VFD) to fabricate ultrathin gallium oxide (Ga₂O₃) sheets under continuous flow conditions. The new method takes advantage of high mass transfer in liquids, and has potential for creating 2D materials, and other nano-materials from liquid metals. Conducting atomic force microscopy for Ga₂O₃ nanosheets sandwiched between a platinum AFM tip and a Si substrate show that they form a highly insulating material reducing the current between the tip and the substrate by over three orders of magnitude. In addition, the Ga₂O₃ nanosheets have electrocatalytic activity for hydrogen evolution, with a Tafel slope of 39 mVdec⁻¹ revealing promoting effects of the surface oxidation (passivation layer). This highlights the potential utility of the ultrathin Ga₂O₃ nanosheets as an alternative to noble metal-based electrocatalysts.

Over the past decade, 2D-nanomaterials have captured the attention of the scientific community, with their extraordinary properties and diversity in applications, seemingly having no boundaries. Nevertheless, there are shortcomings on gaining access to such material where scalability is addressed. This even applies to ubiquitous graphene, for the fabrication of high quality atomically thin sheets, in overcoming the strong van der Waals forces between the layers, and the limited dispersion prowess of the material in organic solvents. While graphene itself is a zero-band gap semiconductor and exhibits quasi metallic features, it exhibits limitations in applications primarily for use in devices and electronics [4, 5]. Having access to a library of 2D-nanomaterials with different properties offers scope for being able to tune the properties of the materials, and this has emerged as a driver for developing 2D-nanomaterials beyond graphene. A number of 2D materials that have recently emerged including transition metal dichalcogenides (TMDs), layered metal oxides, 2D inorganic compounds, hexagonal boron nitride (*h*-BN), layered double hydroxides (LDHs), black phosphorus (BP) and other elemental main group metals and metalloids [5-15]. 2D-nanomaterials derived from liquid metals and/or eutectic melts of the metals, in particular, are envisaged to break new barriers, offering unique properties and potential in applications [16-23]. In addition, it is a significant advantage that any development as such needs to incorporate the principles of green chemistry to minimise the likelihood of any downstream issues, including adverse effects on the natural environment, with the process being readily scalable. We have recently explored the potential of mechanical energy induced within thin films of liquid in the variable angle vortex fluidic device (VFD), Figure 1a, for the synthesis and manipulation of nanomaterials, with the effectiveness of this type of processing in exfoliation of 2D materials, including graphene, *h*-BN and black phosphorus [24-26]. This approach has been successful for generating such material high in green chemistry credentials, without the need for surfactants and harsh chemicals, thereby minimising the waste stream, with the processing simple and low costing, using low molecular weight solvents and under continuous flow conditions. The angled VFD with an optimal tilt angle of 45° (maximum cross vector between centrifugal and gravity) spun at high rotational speeds has remarkably diverse range of applications beyond the exfoliation of 2D materials, including scrolling of graphene directly from graphite flakes, laser assisted controlled slicing of carbon nanotubes, controlling chemical reactivity and selectivity, biocatalysis and probing the structure of self-organised systems [27-33], also incorporating green chemistry principles within the processing.

Herein, we report a simple biphasic method involving liquid gallium and an organic solvent for the *in-situ* generation and exfoliation of Ga₂O₃ sheets, yielding extremely thin sheets with lateral dimensions that are of the lateral dimensions of the bulk gallium layer centrifugally thinned. Gallium metal is a liquid at room temperature (m.p. 29.7 °C) having negligible vapour pressure, with the solid state exhibiting both covalent and metallic bonding, and excellent electrical and thermal conductivity [34]. Also important is its low toxicity making the melt an attractive alternative to toxic mercury, and making it useful for a number of applications [35-39]. Similar to other liquid metals and alloys, gallium features a self-limiting thin oxide layer under ambient conditions, which partly contributes to the excellent properties the liquid metal has to offer at the metal air interface [40]. 2D Ga₂O₃ sheets and nanoparticles have been previously reported using a variety of synthetic routes with the most common method involving high intensive cavitation energy, the squeeze-printing process whereby liquid gallium is forced between two substrates, and a nebulization technique with

all resulting in surface oxidation, affording a nanometer thin layer of the oxide [20, 23, 40-42]. We hypothesised that in the VFD, this layer has the potential to be exfoliated in contact with a dynamic thin film of solvent, thereby exposing fresh metal for rapid oxidation under high mass transfer of oxygen into the film of metal, as a continuous flow exfoliation process, one layer of the 2D material at a time. Exfoliation of 2D material in the VFD is under controlled mechanical energy input in time and place and we also hypothesised that this would lead to uniform sized sheets of any exfoliated material. While metal oxide layers can be transferred to other surfaces [22, 40], strategies for direct transfer into a solvent for fabricating designer material are wanting. Also noteworthy is that the mechanical energy in a liquid over the liquid metal in the VFD can overcome the otherwise formation of a rigid mechanical shell (oxide layer) around the droplet of liquid metal, thereby attenuating its exfoliation.

Fig.1 | VFD mediated fabrication of ultrathin Ga_2O_3 sheets. **a** Schematic of the VFD illustrating its salient features; **b-c** Bright field TEM images of an ultrathin sheet; **d-e** HRTEM images illustrating the lattice spacing of the sheets of ~ 0.25 nm and **f** EDS maps of the corresponding sheet in **b**; **g** an average thickness distribution plot based on AFM measurements; **h-i** AFM height image of the ultrathin sheets and **j** EDX map of the ultrathin sheet confirming the presence of Ga and O on the surface of the area corresponding to the section in **i**.

The VFD was the thin film platform of choice given its utility in the top down manipulation of a diverse range of nanomaterials, having exquisite control of morphology, size and dimensions of particles size to suit specific applications, for either exfoliation or exfoliation with scrolling of the 2D material as discussed above. The key difference now is that the processing is essentially a biphasic system with the source of the 2D material being surface oxidised liquid metal. Biphasic processing in the VFD thus far has been around immiscible solvents including water, for fabricating nanomaterials [43, 44] and the separation of proteins [45]. To put it into perspective, the VFD features a borosilicate or quartz glass tube rotating at high speed (usually rotated between 2000 and 9000 rpm) inclined relative to the horizontal position, which is typically optimal for a specific process at 45° . Liquid is continuously delivered to the bottom of the glass tube, which then forms a dynamic thin film,

Fig. 1a. The VFD encompasses a number of unique operating features that allows for efficient mass transfer of gases, intense micromixing of the reaction mediums and rapid dissipation of heat within the system which in combination is highly effective for the exfoliation of the Ga_2O_3 nanosheets.

Results and discussion

Synthesis and characterization of the Ga_2O_3 sheets. The design of our processing method was established based on systematically exploring the process parameters of the VFD (rotational speed, ω , and inclination angle, q), the choice of solvent, temperature of the system and residence time of liquid entering the tube and exiting at the top. Gallium solid was crushed in a mortar and pestle to finer powder particles prior to immersing in 1 mL of *n*-propanol (10 mg/mL). *n*-Propanol was the choice of solvent after careful optimisation with other polar and non-polar solvents within the green chemistry scope, also including dimethylformamide (DMF), toluene, *i*-propanol, methanol, *o*-xylene and mesitylene. The mixture was then heated on a hot plate to *ca* 30 °C for ~ 60 seconds to achieve a molten liquid which was then subsequently transferred to a VFD quartz tube (20 mm OD, 17.5 mm ID, 18.5 cm long). The VFD process was optimised by systematically varying the rotational speed (4000 rpm to 9000 rpm) and the inclination angle (0° to 90°), with the optimised conditions 7000 rpm and θ 45° respectively. The optimised speed is consistent with mixing times experiments undertaken to gain insight into the nature of the fluid dynamics within the thin film [46]. We observed a minimum time taken for *n*-propanol to mix and form a uniform film at the 7000 rpm speed (Supplementary Fig. S1) which corresponds to the presence of beneficial Coriolis and Faraday wave effects in the thin film [46]. We also carried out a control experiment using an *in situ* heating jacket, a ‘plug and play’ attachment on the VFD (Supplementary Fig. S2) and heated the system at 30 °C and 50 °C at the abovementioned optimised rotational speed and tilt angle. The heating jacket was used to avoid prior heating of gallium metal on a hotplate. However, no sheets were observed using this approach. To address scalability of the process, we translated these above conditions into a continuous flow processing platform, with the liquid gallium (200 mg) placed at the base of the quartz VFD tube with then injection of *n*-propanol at an optimised flow rate of 0.5 mL/min. The gallium oxide sheets were produced in high yield (~60%) following recycling through of the solvent, *n*-propanol. Here we established proof of concept of the potential for scaling up using parallel arrays of VFDs, coupled with recycling of the solvent and the gallium metal, or the use of the larger diameter, 50 mm VFD.

Thus heating the gallium metal to a molten liquid on a hot plate at 30 °C is important prior to processing in the VFD. The temperature of the hot plate was pivotal, with temperatures > 30 °C showing no evidence of sheets being formed, and with temperatures below the melting point of gallium also ineffective. After 30 minutes of processing, the sheets were collected, centrifuged ($g = 3.22$) to remove any contamination and large particles/solids of unreacted gallium within the sample, and then dried for further characterization. Scanning electron microscopy (SEM) and atomic force microscopy (AFM) were initially used to establish the size, morphology and thickness of the sheets. Transmission electron microscopy (TEM), high resolution transmission electron microscopy (HRTEM), Raman spectroscopy, scanning auger, energy dispersive X-ray (EDX) mapping, X-ray photoelectron spectroscopy (XPS), and X-ray powder diffraction (XRD) analysis were then used to further understand the nature of the 2D-sheets.

Gaining insight into the mechanism of formation and surface properties of these ultrathin sheets, involved the use of AFM tapping mode and TEM and HRTEM on samples deposited directly on SiO₂/Si wafers and on holey carbon grids respectively. The ultrathin sheets were observed to be thin with wrinkles on the surface. TEM/EDS (energy dispersive x-ray mapping) and SEM/EDX mapping were used to determine the elemental composition of the sheets, establishing the presence of Ga and O (**Figure 1f**) whilst HRTEM of the sheets showed poor crystallinity with a *d*-spacing of 0.25 nm and amorphous characteristics (**Figure b-e**) [47]. The oxidised gallium at the surface of the ultrathin sheets (**Figure 1**) arises from processing under ambient conditions where there is high mass transfer of oxygen into the thin film of *n*-propanol in contact with the thin layer of gallium centrifugally pinned against the wall of the VFD tube. As previously noted, most liquid metals feature such a self-limiting oxide layer under ambient conditions. The high shear stress generated in the VFD at 7000 rpm and 45° tilt angle is effective in ‘peeling off’ individual layers of ultrathin Ga₂O₃ sheets in contact with liquid gallium through dispersion forces, with subsequent exposed gallium metal then forming another layer of oxidized metal, which is also exfoliated in the same way, and so on. The peeling of the sheets from the surface of the gallium is facilitated by upward flow in the spinning top high mass transport topological fluid flow μm in diameter or less [46]. This flow was established in the VFD from moulding of bismuth metal (m.p. 271.4 °C) which melts on the surface of the tube at room temperature by the mechanical energy induced by down flow of the spinning top flow [46].

AFM height images established the average thickness of the exfoliated sheets at ~5-6 nm (calculated from an average distribution of 50 sheets) (**Figure 1g**). Given that a single oxide layer of Ga₂O₃ has a thickness ~ 1 nm [47], the exfoliated Ga₂O₃ sheets generated in the VFD consist of approximately 5 to 6 layers of the oxide material. The rotational speed of 7000 rpm and 45° inclination angle was critical for high yield exfoliation, with all other combinations studied affording either no sheets or much lower yield, and thus the residence and shear stress are critically important. The low crystallinity and partial amorphous characteristics, as observed from the HRTEM images, **Figure 1d and 1e**, is related to the high rotational speed contributing towards the shorter residence time for the gallium to be within the reaction system and therefore limiting time for reorganisation of the crystal structure. This is consistent with literature whereby unalloyed gallium sheets tend to show amorphous characteristics specifically when fabricated over short time scales [40]. Raman mapping of an ultrathin sheet, (Supplementary Fig. S3), was carried out for bulk gallium (black line), as well as for Ga₂O₃ sheets (blue line). The bulk gallium gave a characteristic band at approximately 300 cm⁻¹ corresponding to the symmetrical stretching of pairs of gallium atoms [48, 49]. The Raman spectra of the generated ultrathin sheets in the present study have several weak and broad bands attributed to the bending and stretching of the Ga-O bond [49]. In addition, there is a strong broad signal between 50 cm⁻¹ and 400 cm⁻¹ with a maximum peak at about ~50-100 cm⁻¹ (Supplementary Fig. S3). The typical characteristic band around 300 cm⁻¹ for gallium metal was not observed, possibly due to the low structural order of the Ga₂O₃ lattice [49]. A slight background signal was also observed in the Raman spectra of Ga₂O₃ which could be due to luminescence effects [49]

Fig. 2 | Surface characterization of the ultrathin Ga_2O_3 sheets. **a** XPS survey spectra of the Ga_2O_3 sheets; **b** High resolution XPS spectra showing two intense peaks at binding energies of 1145.03 eV and 1118.13 eV, which correspond to $2p_{3/2}$ and $2p_{1/2}$ states, respectively of the Ga_2O_3 sheets; **c** XRD pattern of the Ga_2O_3 sheets; **d** Auger depth profile analysis of an ultrathin Ga_2O_3 sheet (SEM image) and the corresponding depth profile graphs for 4 selected points (Area 1-4) (Figure legend: — Ga; — O; — Si) and **e** Thermal analysis using TGA/DSC at 10°C of temperature increase under N_2 .

XPS measurements were carried out to further understand the surface composition and chemical states of the synthesized Ga_2O_3 sheets. The survey spectra showed the presence Ga, O and traces amount of carbon in the sample. The high-resolution spectra of the Ga 2p region afforded a doublet, Ga $2p_{3/2}$ and Ga $2p_{1/2}$ with the positions of the Ga_2O_3 sheets (Fig. 2a-b) peaks compared to the bulk gallium metal (Supplementary Fig. S3). The Ga $2p_{3/2}$ and Ga $2p_{1/2}$ peaks are positioned at 1145.03 eV and 1118.13 eV respectively for bulk gallium with a shift by 0.75 eV to a higher binding energy associated with the Ga-O bonding in Ga_2O_3 [21].

A further understanding of the surface of the sheets was gained through the use of surface sensitive Auger spectroscopy and corresponding depth profiling, to a depth of 40 nm (Fig. 2d). Three separate points on a single sheet were analysed with an additional control point on the silicon surface for comparison. The three separate points were chosen to represent distinct features observed on a sheet; Areas 1-2 were observed to be visibly thicker as a result of wrinkling and folding of the ultrathin sheets, with an approximate thickness of ~40 nm and Area 3 as the thinnest area corresponding to a thickness of 6-7 nm and therefore there are several layers of exfoliated oxide layers in this region, as previously discussed [47]. Depth profiling of Areas 1-2 revealed gallium and oxygen on the top most layer up to a depth of 5 nm. Interestingly, between 5-15 nm, the sheet was observed to contain predominantly gallium with no oxygen present followed by an increase in oxygen at depths between 15-35 nm. This would suggest that there is a region which contains unoxidized gallium. Depth profiling beyond this showed a decrease in both gallium and oxygen. Similarly, for Area 3 as the thinnest region, gallium and oxygen are present on the uppermost layer up to a depth of ~5 nm before a decrease in both gallium and oxygen content beyond 10 nm depth. These findings are important as they

contribute towards the understanding of the mechanism of formation of these ultrathin Ga₂O₃ sheets, and in particular, suggests that although the thinnest layers present are completely oxidised, there also are areas of ‘sandwiched’ unoxidised gallium, specifically around regions with thickness greater than 7 nm.

X-ray diffraction (XRD) was used to characterize the crystal phase, crystallinity and purity of the sheets. Ga₂O₃ can crystallize in a number of polymorphs including α -, β -, γ -, δ - and ϵ phases with the α - phase typically formed as the outer oxide layer in the liquid metal [50]. Amongst these polymorphs, the α - and β - phase are the most structurally documented with the β - phase being the most thermodynamically stable [50]. All diffraction patterns for the Ga₂O₃ sheets could be indexed to α -gallium oxide (Fig.2c) and no additional diffraction peaks of possible impurities here were detected. We attempted to relate the crystal structures of the α - and β -Ga₂O₃ (ICSD numbers: 27431 and 83645 respectively) to match the possible polymorph formed from the synthesized Ga₂O₃ sheets. α -Ga₂O₃ crystallizes in the high symmetry $R\bar{3}c$ double hexagonal close-packed system (Supplementary Fig. S5) while β -Ga₂O₃ crystallizes in the $C2/m$ distorted double hexagonal close-packed system (Fig. 3b). Fingerprint plots generated from the Hirshfeld surface analysis can provide rapid visual means of discriminating the similarities and/or differences in atomic interactions between gallium and oxygen atoms, as well as summarizing the overall distribution of all close contacts quantitatively for both types of polymorph, Fig. 3b and 3e. This includes the variation in the percentage of Ga...O/O...Ga and O...O contacts in the Hirshfeld surfaces. The intermolecular contacts in both α - and β -Ga₂O₃ are overwhelmingly Ga...O/O...Ga (either as donor or acceptor) with 79.6% and 74.2% respectively; while the remaining contribution to the Hirshfeld surface from O...O contacts 20.3% and 24.2% respectively, Fig. 3c and 3f. Both polymorphs showed exceptionally small ranges of Ga...O/O...Ga contacts, evident from the two narrow bands at the lower regions of d_e and d_i on the fingerprint plot. However, the α -Ga₂O₃ showed more intense red and green streaks indicating that the majority of the contacts fall within the short range and can be rationalised in terms of more efficient packing amongst the atoms. O...O contacts are less dominant in the α -Ga₂O₃, as judged by the sparseness and colour of the dots in the fingerprint plot.

Fig. 3 | Hirshfeld surface analysis. (a and d) Hirshfeld surfaces mapped over d_{norm} for α - and β - Ga_2O_3 respectively. (b and e) Two dimensional fingerprint plots of α - and β - Ga_2O_3 respectively. (c and f) Fingerprint plots delineated into $\text{Ga}\cdots\text{O} / \text{O}\cdots\text{Ga}$ and $\text{O}\cdots\text{O}$ contacts for α - and β - Ga_2O_3 respectively.

The thermostability of the Ga_2O_3 sheets was explored using thermogravimetric analysis (TGA) and differential scanning calorimetry (DSC). The TGA (Fig. 2e blue line) shows a small weight loss between 90-100 $^\circ\text{C}$ associated with loss of the solvent *n*-propanol physisorbed on the surface of the sheets. A slight weight increase at ~ 495 $^\circ\text{C}$ which we predict corresponds to gallium metal and/or subvalent gallium present sandwiched within the sheets. The DSC (Fig. 2e red line) shows a thermodynamic response associated with a phase transition at ~ 875 $^\circ\text{C}$ which coincides with a weight increase. SEM images show that the phase transition was due to a change in morphology of the ultrathin sheets to fibres of Ga_2O_3 which were shown to be in the β - Ga_2O_3 phase (Supplementary Fig. S6 and Fig. S7).

Fig. 4 | Applications of the ultrathin Ga_2O_3 sheets. (a-c) Electrocatalytic hydrogen evolution reaction of Ga_2O_3 in $0.5 \text{ M H}_2\text{SO}_4$; a Cyclic voltammogram traces of $70.4 \mu\text{g}^{-1} \bullet \text{cm}^{-2}$ as-prepared Ga_2O_3 showing stripping of surface oxygen in the first scan (inset); **b** Forward scans of $70.4 \mu\text{g}^{-1} \bullet \text{cm}^{-2}$ as-prepared Ga_2O_3 NS under N_2 (red), after first (green) and second (black) conditioning cycle between -0.8 and 1.8 V vs. RHE. The blue CV trace represents HER of $140.8 \text{ mg}^{-1} \bullet \text{cm}^{-2}$ Ga_2O_3 under atmospheric gas (air); **c** respective Tafel slopes under different gas conditions and mass-loadings. The low Tafel slope ($39 \text{ mV}^{-1} \text{ dec}^{-1}$) and low overpotential ($\eta (1 \text{ mA} \bullet \text{cm}^{-2}) = 150 \text{ mV}$ vs. RHE) of Ga_2O_3 in this study exhibits activities toward HER which are comparable to platinum group metals on carbon support [51], transition metal phosphides [52] and hybrid metal nanoparticles [53], **d-e Current-potential relationship of the Ga_2O_3 sheets compared to silicon; d** AFM topography image of gallium oxide sheets with thickness of 5 to 30 nm ; **e** I-V measurement compared between Si- Ga_2O_3 -Pt (5 nm (blue) and 30 nm (red)), and Si-Pt (black) junctions. Inset in e corresponds to 30 nm Ga_2O_3 sheet's I-V curve, in scale of nA for current; **f** AFM topography image of Ga_2O_3 wrinkled area with $\sim 100 \text{ nm}$ thickness; **g** I-V measurement compared between Si- Ga_2O_3 -Pt ($\sim 100 \text{ nm}$ (red)) and Si-Pt (black) junctions. Inset in g corresponds to 100 nm Ga_2O_3 sheet's I-V curve, in scale of pA for current. The bias is applied to the surface with bias sweep set between -6 to 6 V . *, $\blacktriangle$, are the location where the IV curves were

collected. Statistics were obtained by measuring the IVs at different locations around the marks in an area of $1\mu\text{m}^2$. Lines are the average of 50 curves collected from each location.

Ga₂O₃ as an active catalyst in electrocatalytic hydrogen evolution reactions (HER). Ga₂O₃ nanostructures have been shown to be efficient supports in photocatalytic water splitting and CO₂ reduction [54-58]. However, little is known about the electrocatalytic hydrogen evolution reaction (HER) [59]. Herein we report the catalytic activity of the Ga₂O₃ nanosheets toward electrochemical HER in 0.5 M H₂SO₄. The recorded cyclic voltammogram traces and calculated Tafel slopes are shown in Fig. 4a-c. The as prepared Ga₂O₃ nanostructures on the glassy carbon (GC) electrode revealed under protective gas (N₂) a broad reduction event between -0.1 and -0.6 volts vs. RHE during the first cyclic voltammetry scan, which disappears during the subsequent numbers of sweeps (Fig. 4a, inset). The broad cathodic reduction during the first scan was reproduced when the same nanostructures were conditioned between -0.8 and 1.8 volts vs. RHE (Supplementary Fig. S8) and studied again under cathodic potentials. Since no dissolved oxygen was present, the first scan event is associated with stripping of the oxide layer that is regenerated under anodic potentials. The oxide layer remains stable during the subsequent conditioning cycles suggesting that the gallium nanosheets react with water under oxidative potentials (Supplementary Fig. S8). Further studies under oxygen-free and ambient conditions showed that the oxide layer plays a crucial role during the electrocatalytic activity of HER. When replacing the nitrogen by atmospheric gas (air) and increasing the mass loading, the Ga₂O₃ nanosheets achieved the highest activity toward HER (Fig. 4b). The calculated Tafel slope of 39 mVdec⁻¹ (Fig. 4c) over a wide range of overpotential, 150 – 600 mV vs. RHE, reveals high production rates of H₂ and suggests that Heyrovsky and Tafel determining rate steps are involved in the mechanism [60]. This is likely due to the absorbed protons by surface oxygen since the highest hydrogen production rate appears also in the potential range where stripping of the oxygen layer occurs (Fig. 4a). The role of surface oxygen as active sites to promote the hydrogen evolution reaction has also been shown in photocatalytic water splitting [58].

Studying the electronic properties of single Ga₂O₃ sheets. Functional oxides, mainly SiO₂, are fundamental to modern microelectronics as high quality insulators, electroluminescent and electrochromic materials, amongst other applications. Considerable effort over several decades has resulted in high quality insulating materials now ubiquitously used in complementary metal oxide semiconductor devices. To really push these technologies into the future, the next-generation of electronic components that can handle great power loads without increasing the size of the electronics systems is needed. Modern devices incorporate few-nanometer thick layers in which electrical stress can be extreme. Therefore, in recent years much effort has been devoted to develop novel gate dielectrics as alternative to silicon oxide for miniaturised electronics. Among them, Ga₂O₃ is one of the most promising dielectric materials due to its wide bandgap (~ 4.8 eV) and excellent chemical/thermal stability. Here, we have studied the insulating electrical properties of the fabricated Ga₂O₃ sheets via conducting atomic force microscopy by wiring Ga₂O₃ sheets of different thicknesses. A highly doped silicon surface was used as the base electrode and a platinum electrode as the tip electrode and the fabricated thin layers of Ga₂O₃ in between. Results show that the current is reduced by over three orders of magnitude (Fig. 4 d-g) when the thickness of the Ga₂O₃ layer reaches 100 nm (Supplementary Table S1). Currents

comparable to a bare Pt–Si junction are only observed above 6 V for a Ga₂O₃ layer of 30 nm thick (Fig. 4 inset in e). This translates to a breakdown voltage of > 0.2V/nm for the fabricated Ga₂O₃ layers which is comparable to highly insulating materials such as SiO_x (~0.4V/nm) that are commonly used as the insulating gate electrodes in metal–oxide–semiconductor field-effect transistor [61, 62]. This is also consistent with recent studies demonstrating Ga₂O₃ as an effective gate electrode in transistors [63–65].

Conclusions

We have established a significant advancement in the area of 2D-nanomaterials, with the development of a simple and robust method for the exfoliation of ultrathin Ga₂O₃ nanosheets with an average thickness of ~5-6 nm, directly from gallium metal. The simple and benign method generates the 2D material in ~60% yield, which is dramatically higher than has been achieved using other methods, and it avoids the use of high molecular weight solvents, surfactants and chemical stabilisers. We have also ensure scalability of the process is addressed at the inception of the science for industry uptake, with the processing under continuous flow. We envisage that this method can be extended to other low melting point metals and metalloids, for fabricating analogous layered and non-layered nanomaterials. The ability to exfoliate the oxide layer from gallium metal suggests that there must be some tangential force associated with lift mechanism in overcoming the centrifugal force in the rotating tube which would otherwise pin the high density oxide to the surface of thin film of gallium metal. Both the tangential force and lift mechanism is consistent with the presence of micron/sub-micron spinning top topological fluid flow in the VFD. This is one of the topological fluid flows in the general model of fluid flow in the VFD which accounts for all the processing outcomes of the device, depending on the nature of the liquid and rotational speed, at a tilt angle of 45° [46] In addition, the ability to prepare highly insulating gallium oxide sheets has potential in device technology, and the catalytic prowess of the ultrathin sheets shows promise for application in water splitting in avoiding the use of precious metals of the transition metals and material for which its use as such is questionable on environmental grounds.

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Supplementary information is linked to the online version of the paper at www.nature.com/nature.

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Author contributions K.V. and C.L.R. designed the experiments and wrote the manuscript. T.P performed and optimised the experimental conditions, K.V performed and analyzed the SEM, AFM, Raman, XPS, XRD and TGA/DSC data, Z.G performed the Scanning Auger measurements, I.L. performed the Hirshfeld analysis, S.R. and N.D performed the single particle electronic studies using conductive force microscopy, S.E. performed the hydrogen evolution reactions, J.R.G. performed the SEM/EDX measurements, C.G. performed AFM height analysis, Q.S. and J.Z. performed the TEM and HRTEM measurements and M.R.A. contributed towards the development of experiments related to the hydrogen evolution reactions . All authors contributed towards editing of the manuscript.

Competing interests The authors declare no competing interests.

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Supplementary information

High shear *in situ* exfoliation of 2D gallium oxide sheets from centrifugally derived thin films of liquid gallium

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Experimental method

Raman Spectroscopy and Microscopy

Raman spectra were acquired using a Witec alpha300R Raman microscope at an excitation laser wavelength of 532 nm with a 100X objective (numerical aperture 0.90). Typical integration times for single Raman spectra were typically 30 s and averaged from 2 to 3 repetitions. Confocal Raman images were acquired with integrations typically 3 to 5 seconds per pixel. Each pixel in the Raman images represents a Raman spectrum with the number of pixels in a typical Raman image representing hundreds to thousands of spectra. Confocal Raman images are generated by plotting the intensity of a specified region of each Raman spectrum that corresponds to a material, versus the X-Y position of the excitation laser as it scans the sample surface.

Atomic Force Microscopy

AFM images were acquired using a Bruker Multimode 8 AFM with a Nanoscope V controller using tapping mode in air, with all parameters including set-point, scan rate, and feedback gains adjusted to optimize image quality. The AFM probes used were Mikromasch HQ:NSC15 Si probes with a nominal spring constant of 40 N/m and a nominal tip diameter of 16 nm. The scanner was calibrated in the x, y, and z directions using silicon calibration grids (Bruker model numbers VGRP: 10 μm pitch, 180 nm depth, PG: 1 μm pitch, 110 nm depth). Analysis of AFM images was performed using Nanoscope analysis software version 1.4. Presented AFM topography images were flattened, and the cross sections acquired using the section tool in the Nanoscope analysis software.

Scanning Auger Spectroscopy

The AES analysis was conducted with a PHI 710 Scanning Auger Nanoprobe. The Ga_2O_3 sheets were drop-casted onto silicon wafers which were used for the characterisation. Ar^+ ions were used in the depth profiling for etching the sheets. The Scanning Auger Nanoprobe parameters were as follows: etching speed, 0.24 nm s^{-1} ; ion voltage, 2kV; interval; 6 s; depth; 40 nm; and scanning area of $0.19 \mu\text{m}$. Silicon dioxide was as a standard for the etching speed determination. The Scanning Electron Microscopy on the Scanning Auger Nanoprobe used a current intensity of 10 nA and an acceleration voltage of 10kV. Ga_{LMM} , O_{KLL} and Si_{LVV} Auger lines were used for plotting the depth profiles of each sample.

Conductive Atomic Force Microscopy (C-AFM)

Conductive- atomic force microscopy (C-AFM) was used for imaging and dc conductivities. Current-voltage (I–V) data were collected by a Bruker ICON head with peak force Tuna module at room

temperature using conductive platinum tip (RMN-25PT300B) having spring constant of 18 N.m⁻¹. The image resolution, scan rate and peak force set point were set to 256 points, 1 Hz and 50 nN, respectively. Here, n-type (phosphorus doped) single-side polished Si wafer with the thickness of 500-550 μm and (111) $\pm 0.05^\circ$ (with resistivity of $<0.002 \Omega\cdot\text{cm}$) was used.

Electrocatalytic hydrogen evolution reactions (HER)

Electrocatalytic hydrogen evolution reactions (HER) were performed on an AUTOLAB potentiostat (Metrohm AG, Switzerland) using a glassy carbon (GC) electrode (0.071 cm²) as working (WE), a platinum wire as counter (CE) and Ag|AgCl (1 M KCl) as reference electrode (RE) in 0.5M H₂SO₄ as electrolyte solution. The glassy carbon electrode was polished with 0.3 μm Alumina (Micro Polish, IONODE) prior to changing the mass loading. Here, 5 or 10 μL of 1 mg/mL Ga₂O₃ nanostructures in n-propanol were drop-casted onto the WE, dried under ambient temperature for 3 h and tested under oxygen-free and atmospheric gas conditions using N₂ as protective gas. This equals to 70.4 and 140.8 $\mu\text{g}/\text{cm}^2$ mass loading of Ga₂O₃ electrocatalyst. Higher mass-loadings showed leaching of the catalysts from the glassy carbon disc once dispersed in 0.5 M H₂SO₄ electrolyte solution. Hence, for the sake of reproducibility and to avoid manipulation of the geometric surface of the GC working electrode, only 1 or 2 droplets of electrocatalyst (5 and 10 μL) were drop-casted onto the GC surface. All recorded working potentials vs. Ag|AgCl (1M KCl) were converted into the reversible hydrogen electrode (RHE) according to the equation $E_{(\text{RHE})} = E_{(\text{Ag}|\text{AgCl})} + 0.059 \cdot \text{pH} + E^0_{(\text{Ag}|\text{AgCl})}$, where $E^0_{(\text{Ag}|\text{AgCl}, 1\text{M KCl})} = 0.235 \text{ V}$ [1].

Supplementary Figure 1

Fig. S1 Mixing times of the solvent in the VFD at the different rotational speeds were measured to identify the optimised speed for the processing of liquid gallium. 1mL of *n*-propanol was placed in the VFD operating at an inclination angle of 45° and varying the rotational speed (2000–9000 rpm) and the time taken for a drop of dye to uniformly mix with the bulk liquid was measured in seconds (all measurements were carried out in triplicates).

Supplementary Figure 2

Fig. S2 (a) Control experiment using a 'plug and play' heating jacket as an alternative to heating on a hotplate and (b) Thermal imaging of the VFD with the heating jacket showing a temperature of 50 °C.

Supplementary Figure 3

Fig. S3 Raman analysis of a Ga_2O_3 sheet; **a-b** SEM and AFM height image of a Ga_2O_3 sheet; **c** Raman map of the sheet imaged in (a-b) and **d** The Raman spectra that corresponds to the map in (c) mapping the peak labelled with the red arrow, $\sim 50\text{-}100\text{ cm}^{-1}$

Supplementary Figure 4

Fig. S4: XPS survey spectra of bulk gallium metal, and (b) High resolution spectra of the doublet 2p region

Supplementary Figure 5

Fig. S5: XRD spectra for α - and β -Ga₂O₃. Spectra were computed using Mercury software using the crystal structures of the α - and β -Ga₂O₃ (ICSD numbers: 27431 and 83645 respectively).

Supplementary Figure 6

Fig. S6: Characterization of material after thermal analysis. TGA/DSC was carried out at 10 °C min⁻¹ of temperature increase under N₂. (a) A white powder was collected after heating at 950 °C and (b) SEM images of gallium oxide fibres/scrolls formed after heating at 950 °C.

Supplementary Figure 7

Fig. S7: XRD analysis of the gallium oxide fibres/scrolls formed after heating at 950 °C.

Supplementary Figure 8

Fig. S8: Recorded cyclic voltammogram (CV) traces of HER on Ga_2O_3 nanosheets after 1st and 2nd conditioning cycles; (b) Recorded CV traces of the conditioning cycles in the potential range -0.8 to 1.8 V vs. RHE. All CV traces were recorded under protective gas condition using nitrogen.

Supplementary Figure 9

Fig. S9: XRD analysis before and after the electrocatalytic hydrogen evolution reaction (HER). The amorphous α - Ga_2O_3 sheets synthesized in the VFD were observed to exhibit crystalline characteristics after electrocatalytic treatment.

Supplementary Table 1

Thickness (nm)	Average current at 6 V (nA)
5	> 500
30	3
100	0.05-0.1

Table S1: Average current at 6V at different thicknesses of the Ga₂O₃ sheets

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